



JUL 2 3 2002

Sheet 1 of 1

	SADE AS	<u>, </u>			IC 170	10		
FORM PTO-1449				ATTY DOCKET NO.	SERIA	SERIAL NO.		
INFORMATION DISCLOSURE STATEMENT				50439 09/313,045			5	
					APPLICANT(S): Barstad et al.			
		(ART UNIT: 1741		
		UNITED	STATES PATEN	T DOCUMENTS				
EXAM. INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPR	
Ш.	AA	3,876,513	04/08/75	Brown et al.				
	AB	4,098,656	07/04/78	Deuber	CORV			
	AC	4,530,741	07/23/85	Rosenberg	ORIGIN	PAPER ALLY FILE	is n	
	AD	4,913,787	04/03/90	Kiso				
	AE	5,051,154	09/24/91	Bernards et al.				
	AF	5,068,013	11/26/91	Bernards et al.				
	AG	5,174,886	12/29/92	King et al.				
	AH	5,223,118	06/29/93	Sonnenberg et a	1.			
	AJ	5,858,870	01/12/99	Zheng et al.				
	AK	5,433,840	07/95	Dahms et al.				
4	AL	2,424,887	07/47	Henricks				
1110.	AM	5,151,170	09/92	Montgomery et a	1.			
	AN	4,347,108	08/82	Willis			Ī	
Ш.	AO	4,336,114	06/82	Mayer et al.				
	AP	4,036,710	07/77	Kardos et al.				
	AQ	6,113,771	09/00	Landau et al.				
	AR	5,068,013	11/91	Bernards et al.				
W.	AS	5,051,154	09/91	Bernards et al.				
W.	AT	6,024,857	02/00	Reid				
	OTHER DO	CUMENTS (INCLUDIN	G AUTHOR, TITLE	, DATE, PERTINENT P	PAGES, ETC.)		,	
114.	Pla	ating Electrolyte	erconnect, Advance Optimized for S	nced Interconnect M 200 nm, Bottom-up T	Materials, "Na Trench Fill" S	noplate	Company,	
Examiner:	11/2/12/	190		Date: 8	27/02			